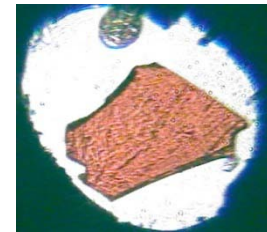
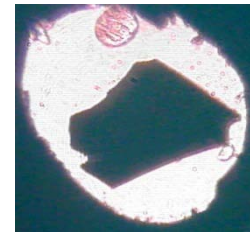
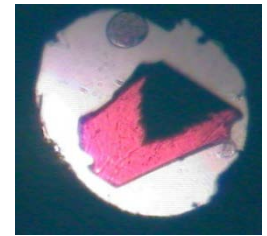
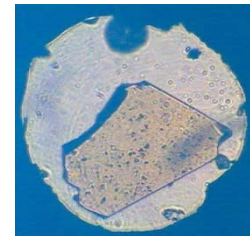
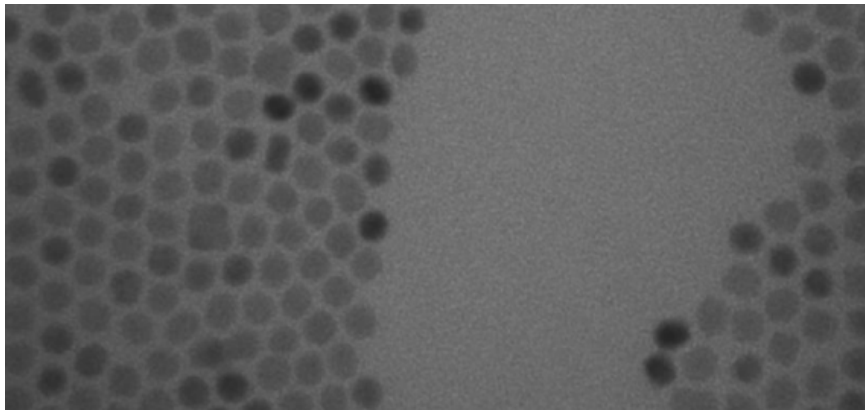


Optical measurements under high pressure in semiconductor nanostructures

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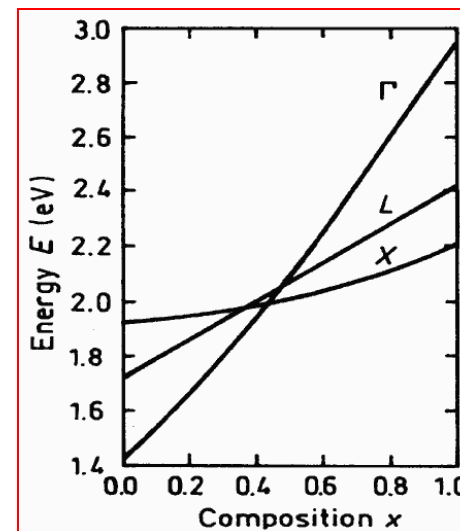
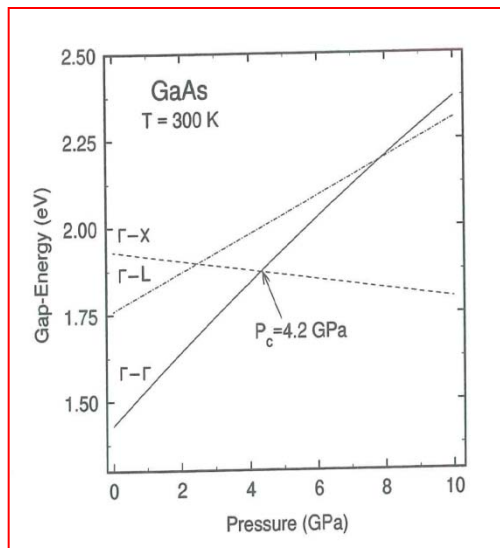
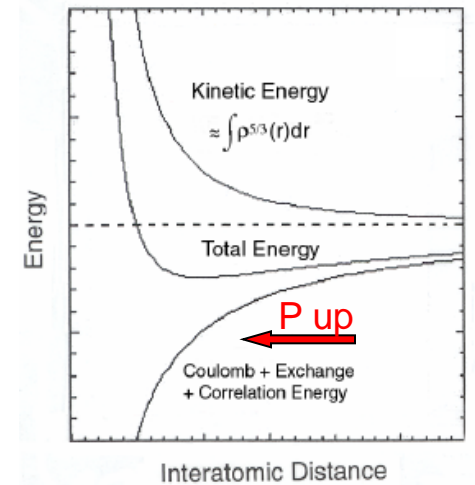


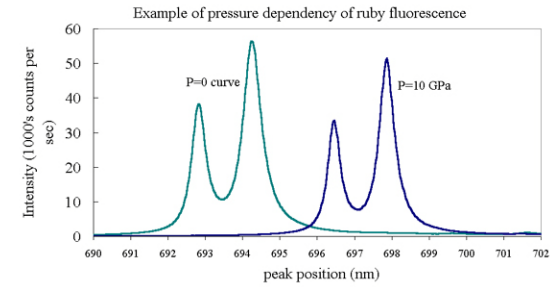
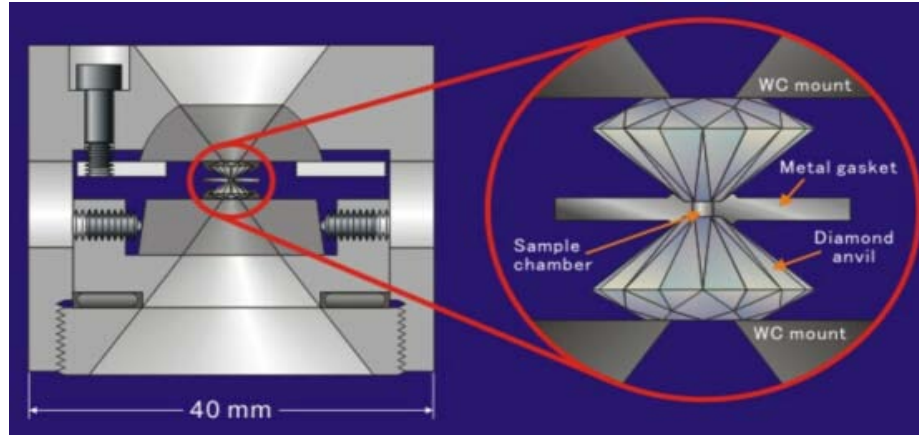
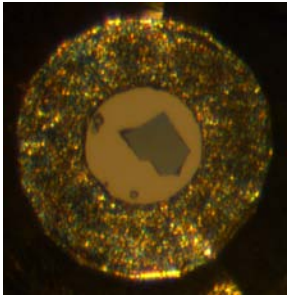
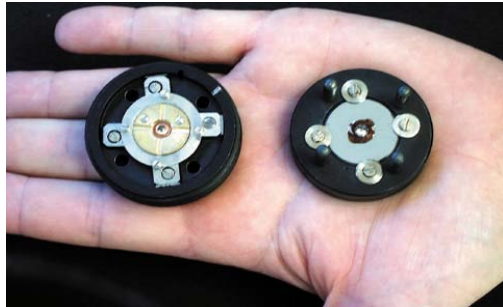
Outline of the talk

- Why do we study materials under high pressure?
- Experimental: high pressure techniques
- Optical properties of PbSe nanocrystals
- Optical properties InAs quantum wells and quantum wires
- Large metastability range of w- and rs-ZnO nanoparticles
- Conclusions

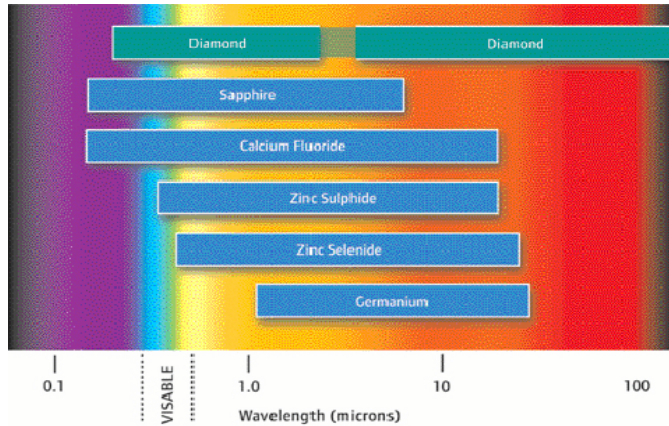
Why do we study materials under high pressure?

- High pressure is the only available tool to explore the interatomic potentials as a function of the interatomic distance.
- High pressure experiments are the most efficient tests of ab-initio electronic structure calculations.
- High pressure changes the band ordering in semiconductors (equivalence between chemical and mechanical pressure).

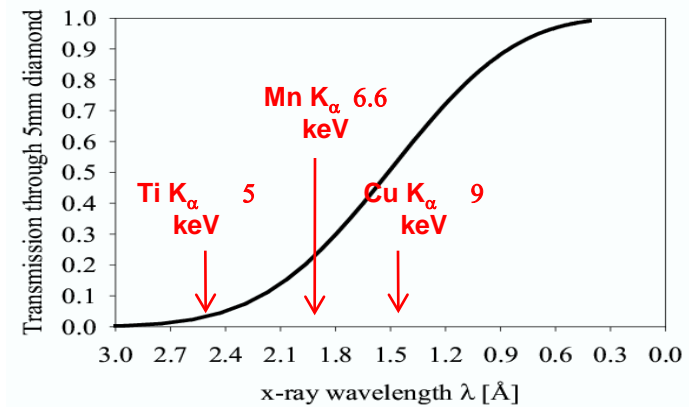




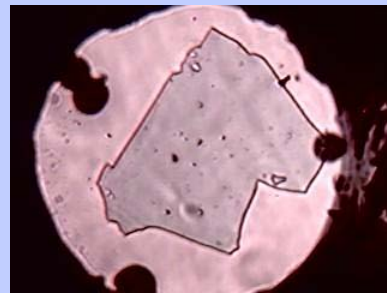
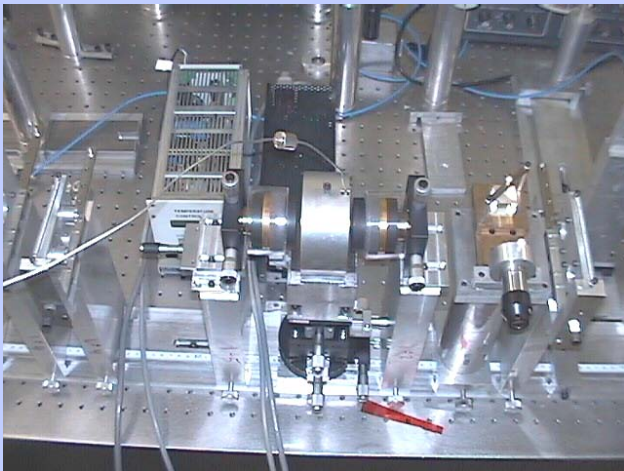
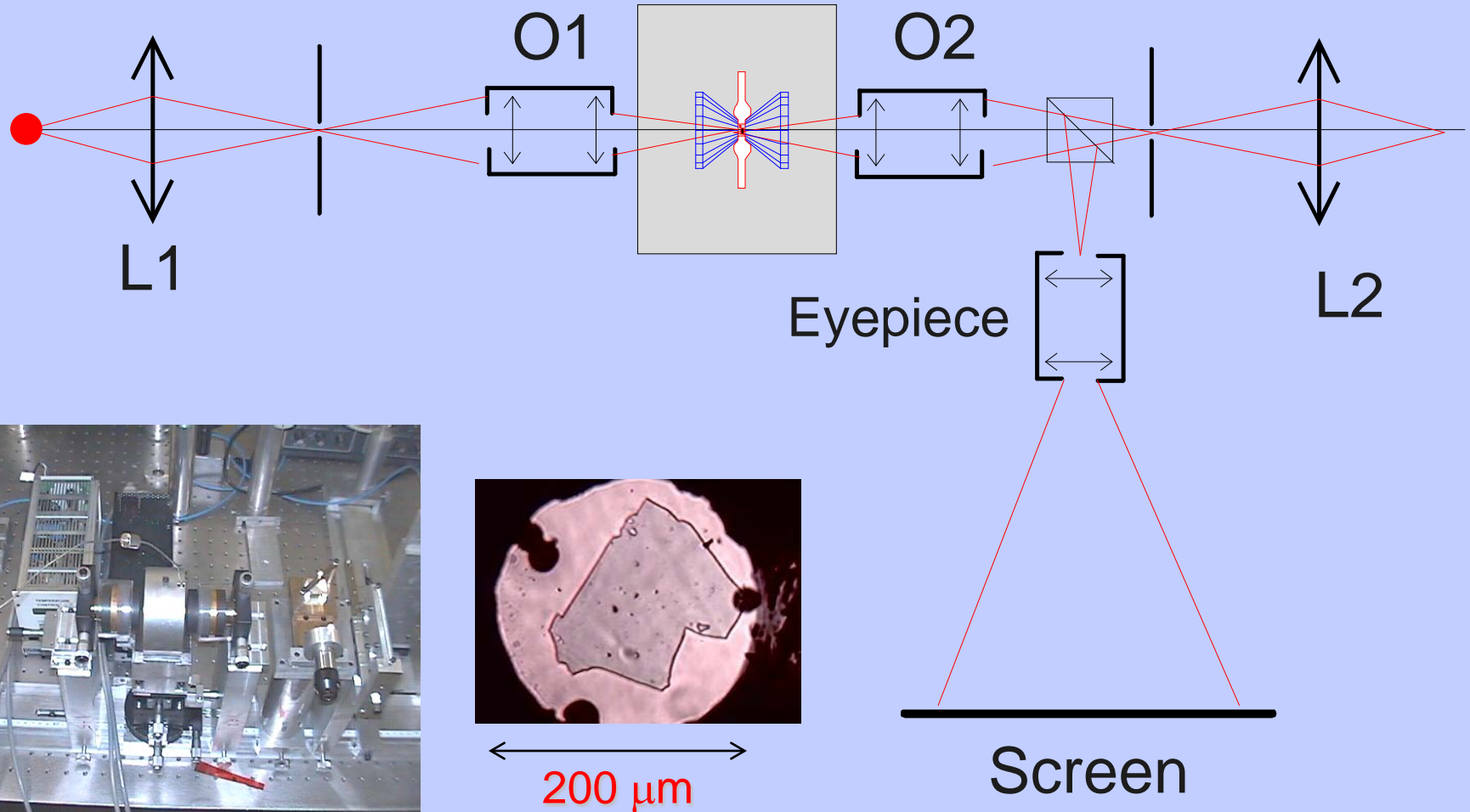
Transparency of diamond UV-VIS-IR



XR transmission of diamond



Microscopic optical bench



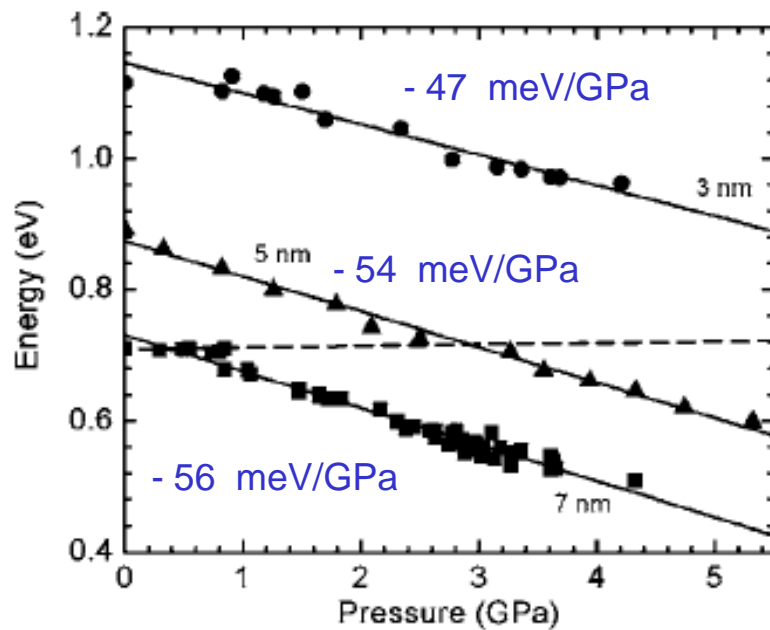
200 μm

Screen

Optical properties of PbSe nanocrystals under high pressure

- Interest for solar cells: multiexciton processes
- Interest for LEDs: wide emission wavelength tuning (0.28–1 eV) and large emission efficiency

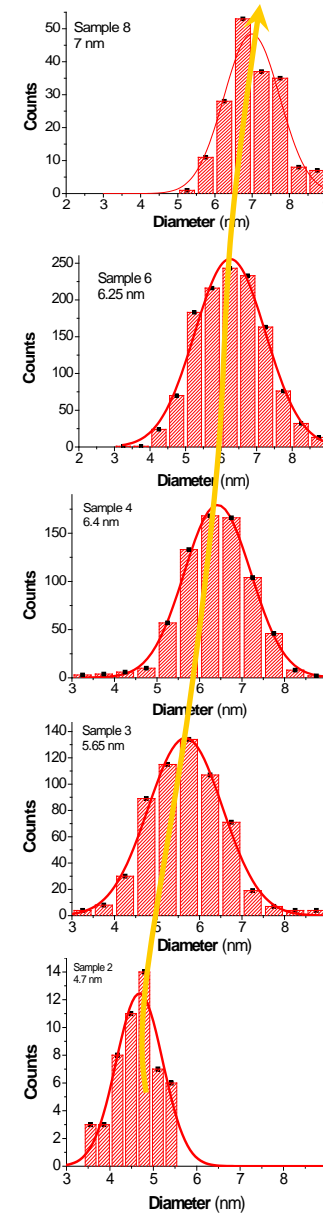
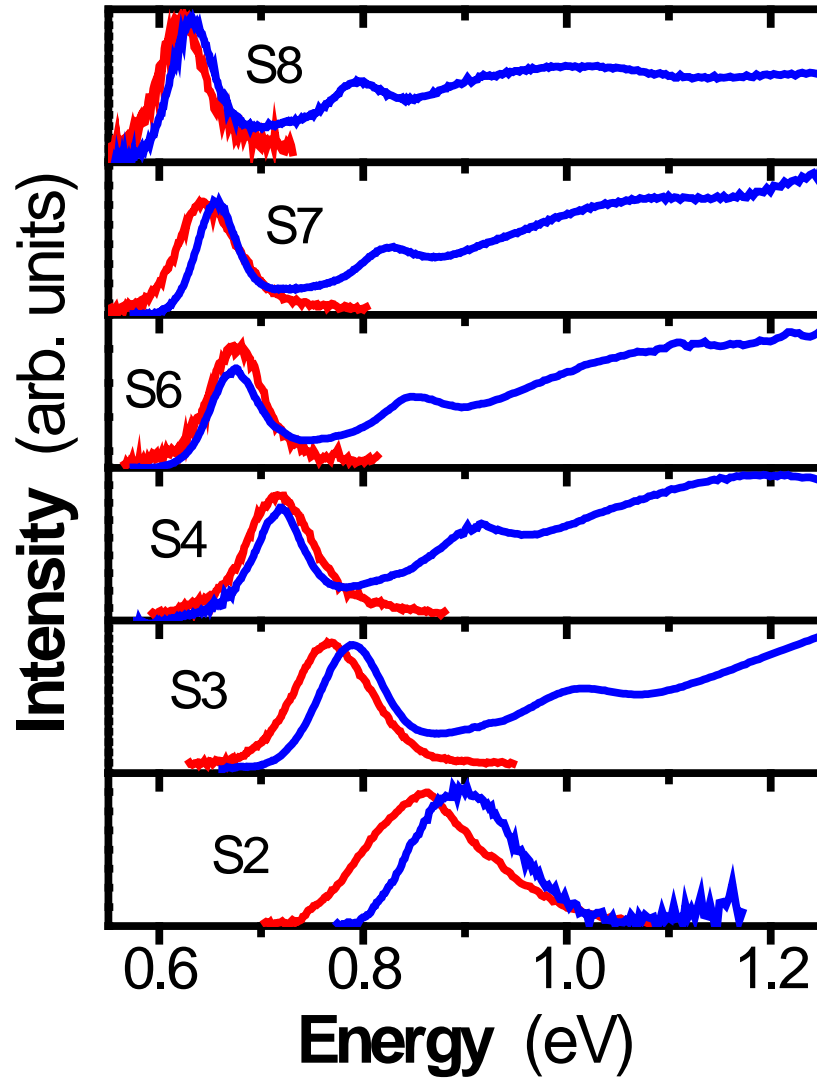
Recent results on PbSe NCs under pressure



No change of confinement energy under pressure!

Previous results on PbSe gap pressure coefficient: - (85 – 100) meV/GPa

PbSe nanocrystals: size effect



Effective mass model for size confinement in PbSe NCs

- Finite potential barriers for carrier confinement

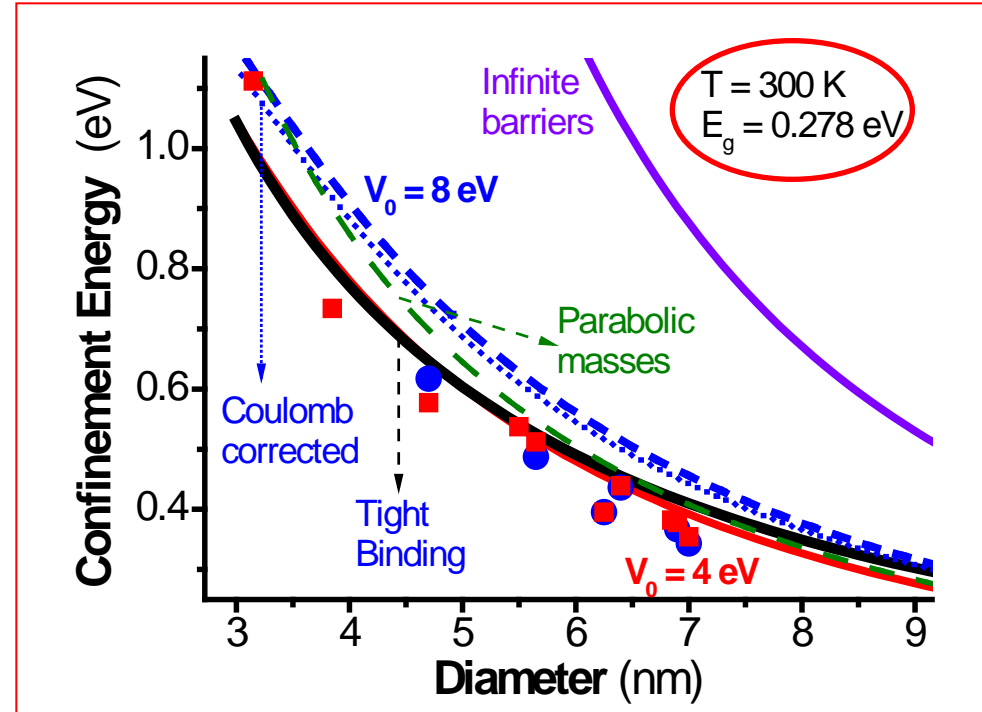
$$x \cot(x) = 1 - \left(\frac{m^*}{m_0}\right) - \sqrt{\left(\frac{m^*}{m_0}\right) \left(\frac{V_0}{\Delta} - x^2\right)},$$

where $x = k_{in} r_0$. $\frac{1}{\Delta} = \frac{2m^* r_0^2}{\hbar^2}$ $k_{in}^2 = \frac{2m^* E}{\hbar^2}$ and $k_{out}^2 = \frac{2m_0 |E - V_0|}{\hbar^2}$.

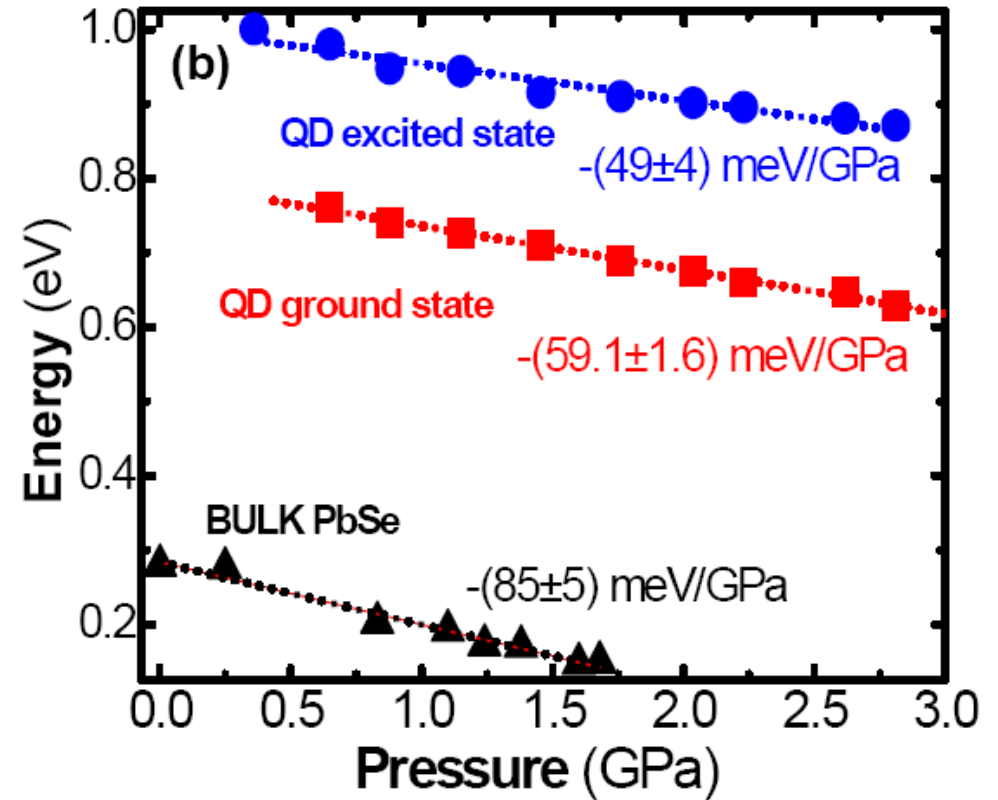
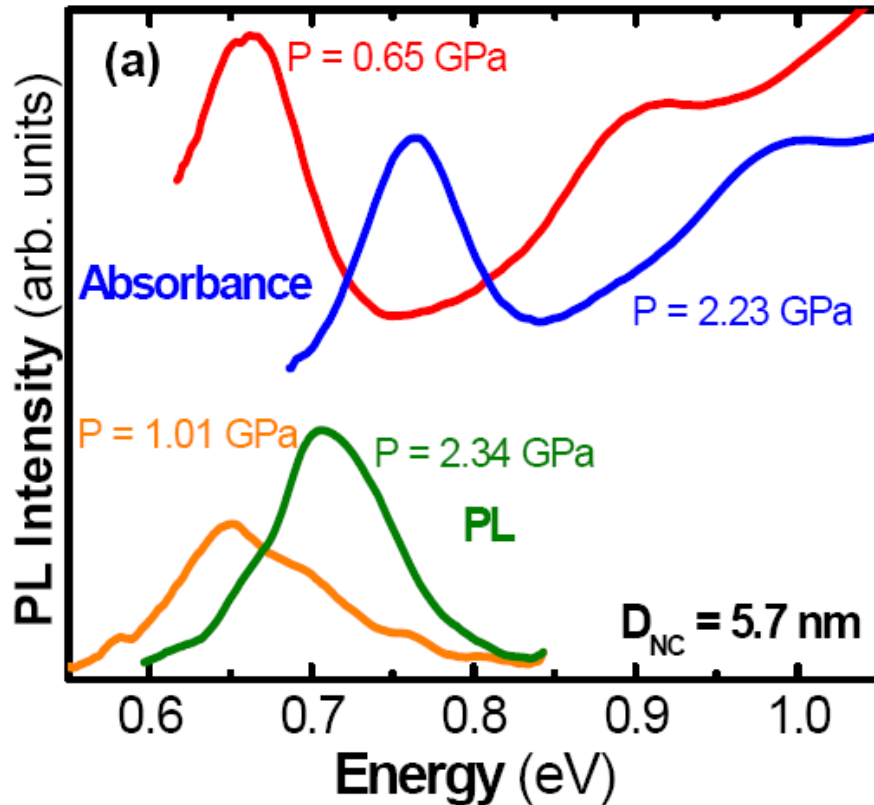
- Non parabolic effective masses

$$m_{e,h}^*(E, X) = \frac{m_{e,h}^*(0, X)}{\sqrt{1 - \frac{m_{e,h}^*(0, X)}{m_0} \frac{E}{E_{np}}}}; \quad X = T, P$$

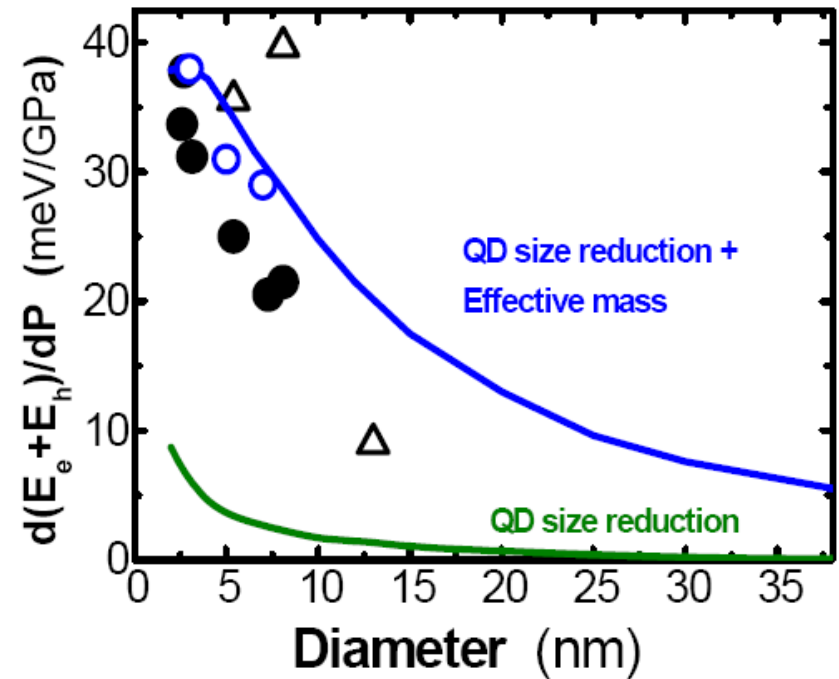
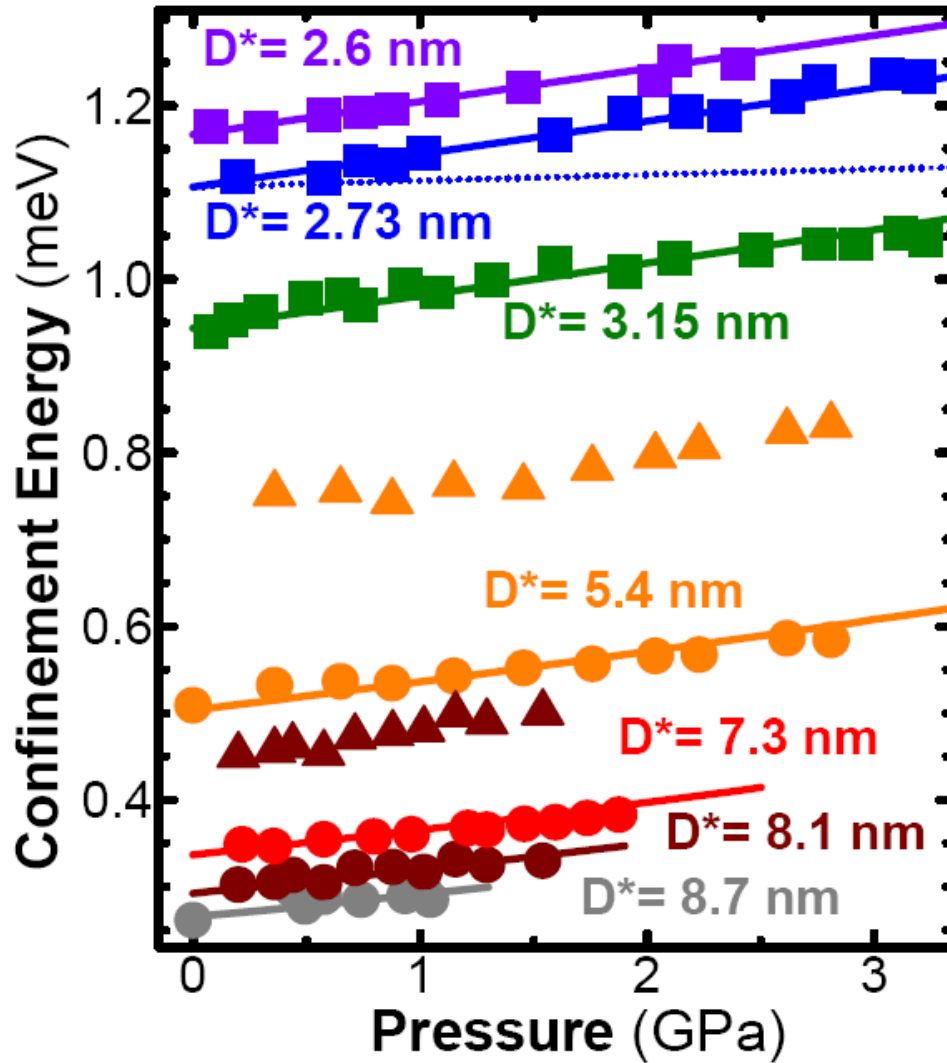
$$E_{np} = \frac{\hbar^2}{8m_0\gamma} = 0.05 \text{ eV}; \quad \gamma = 1.9 \times 10^{15} \text{ cm}^{-2}$$



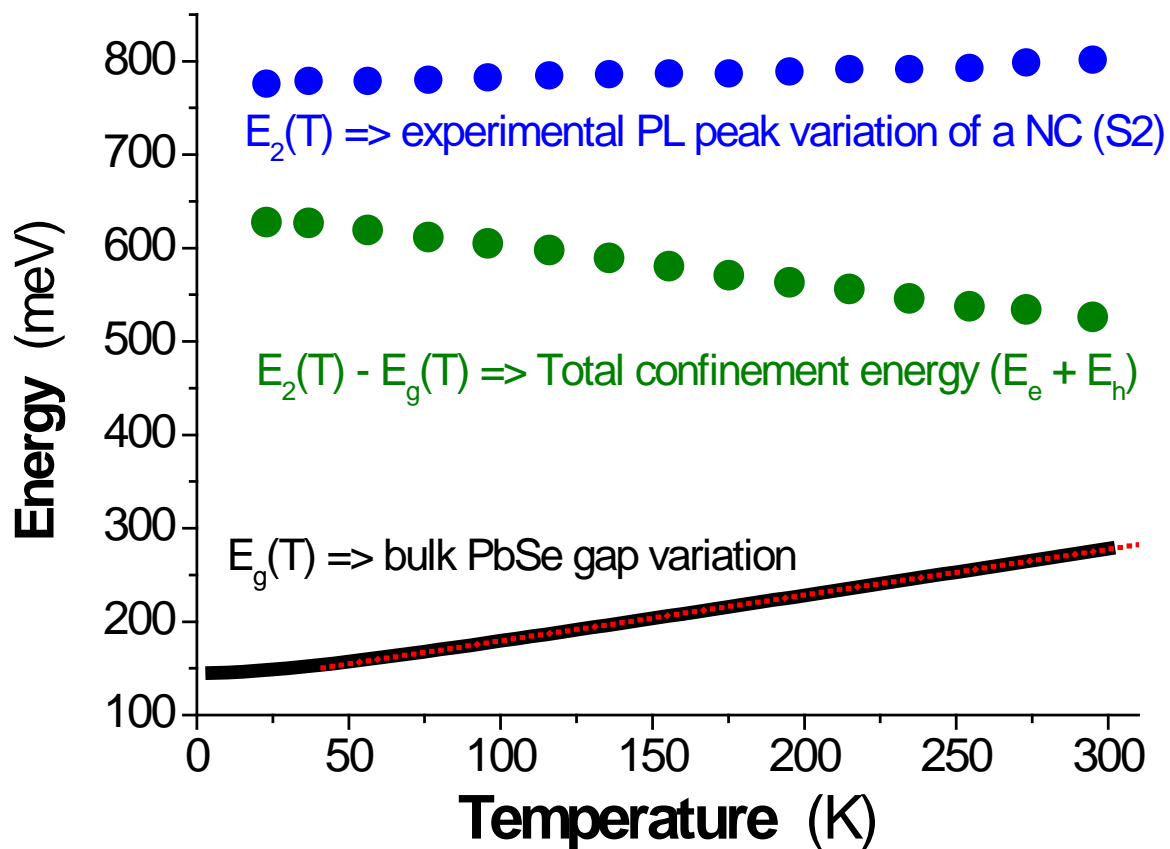
PbSe (bulk and NCs) under high pressure



Confinement energy in PbSe NCs under high pressure

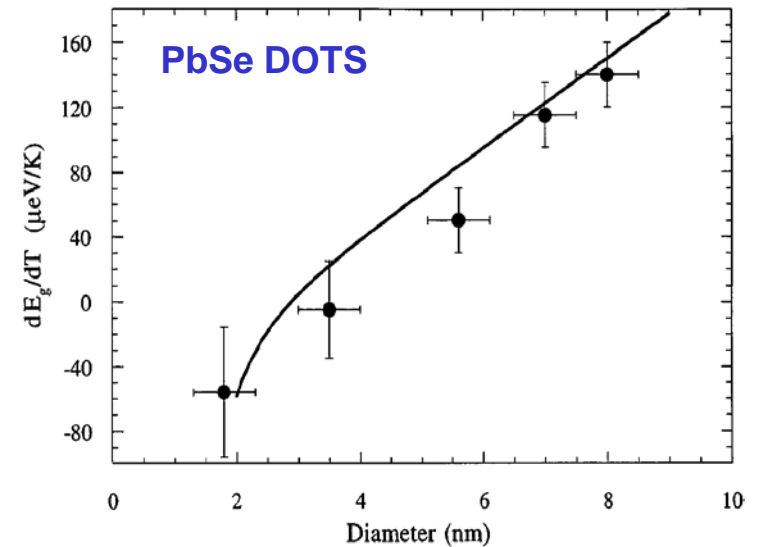
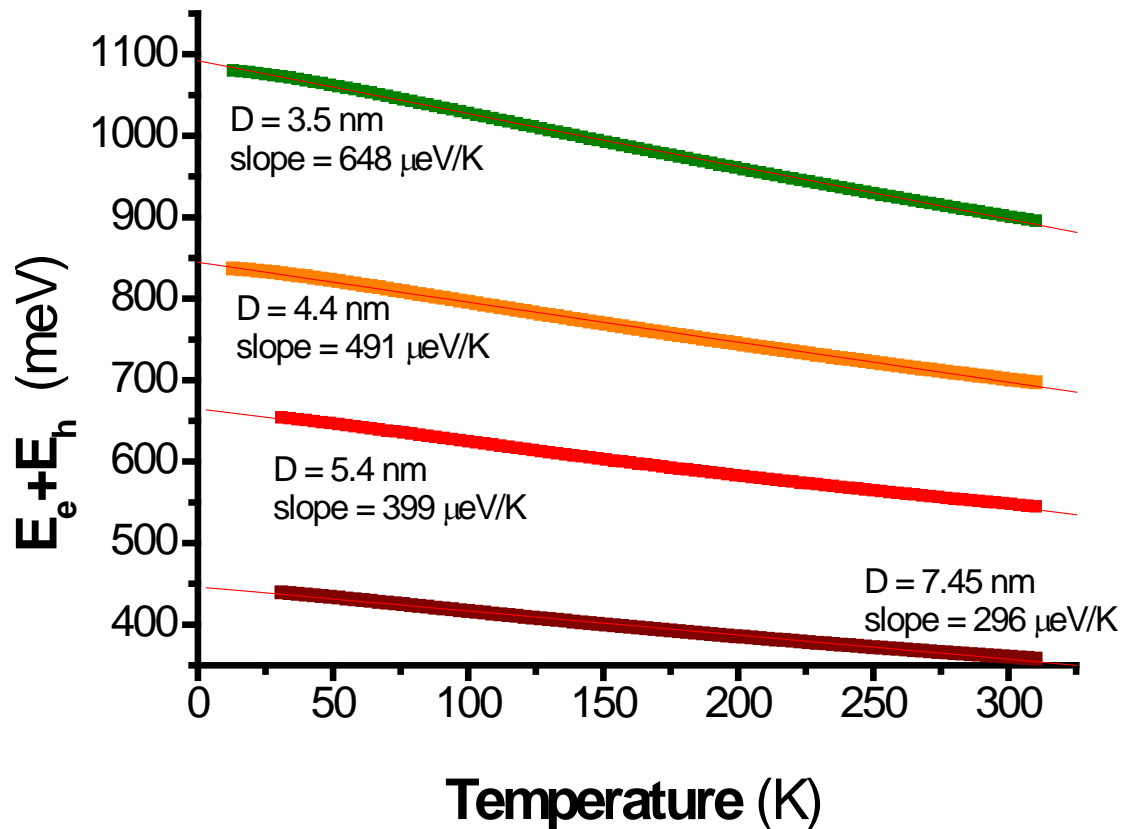


Temperature dependence of electronic transitions in PbSe NCs



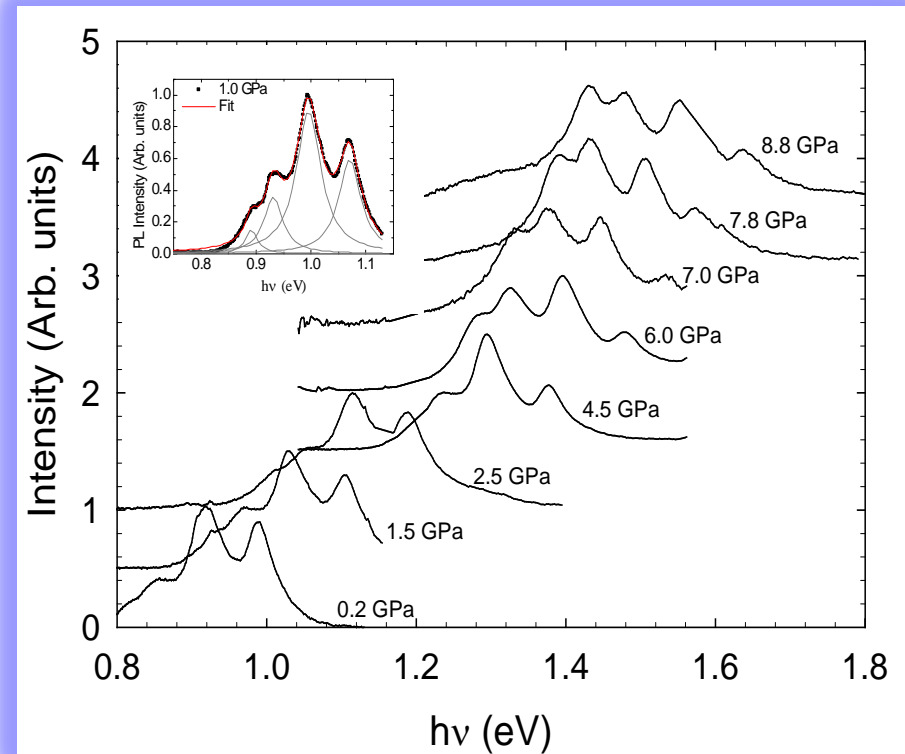
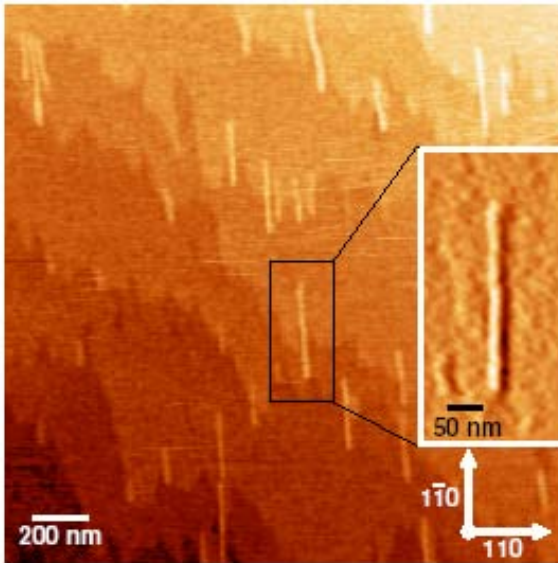
Temperature dependence of the confinement energy in PbSe NCs

The increase of the effective mass with T makes the total confinement to decrease with higher rates for NCs with smaller diameters.



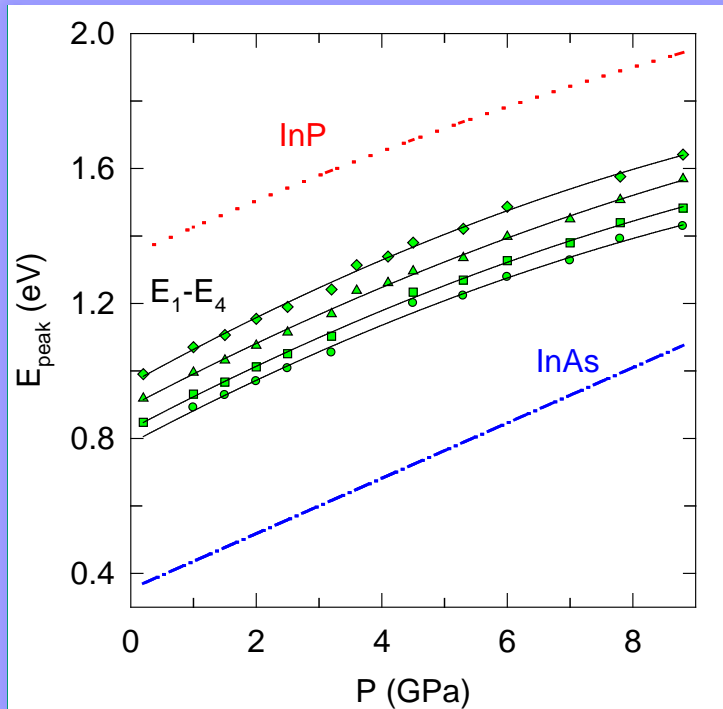
PL in InAs/InP quantum wires under pressure

- Dimensions of QWires :average height (2.5 nm), average width (21 nm), and average length (185nm)
- QWires are randomly distributed
- QWires coexist with flat QWell islands of 1-2 ML high



- ✓ Four PL bands observed. The two bands with higher energy mainly arise from exciton recombination at the QW-like islands

PL in InAs/InP quantum wires under pressure



Peak	E_0 (eV)	a_1 (meV/GPa)	a_2 (meV/GPa ²)
QWr- E_{1A}	0.786	99	-2.9
QWr- E_{2A}	0.828	98	-2.7
QW- E_{3A}	0.896	98	-2.5
QW- E_{4A}	0.964	103	-3.0

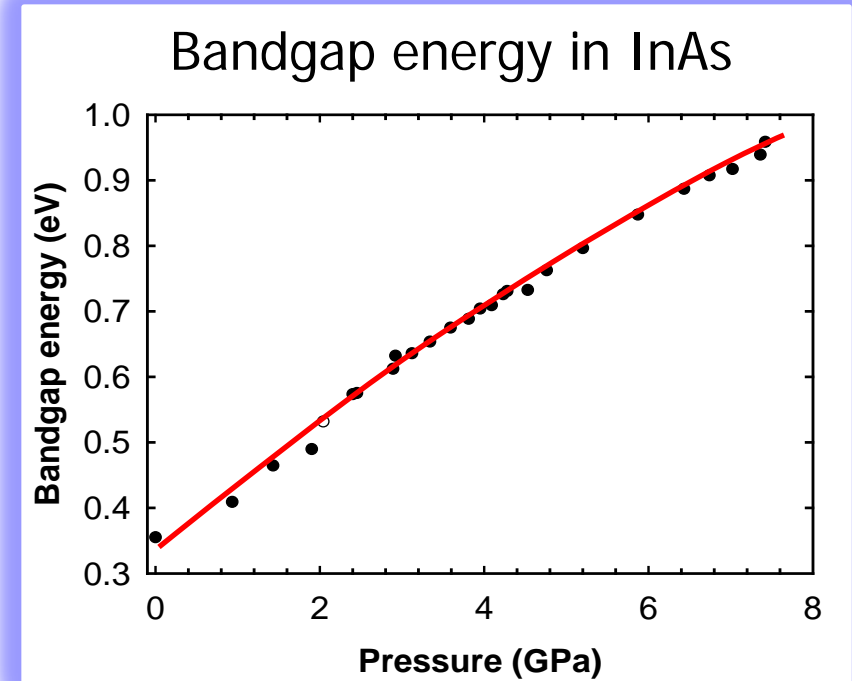
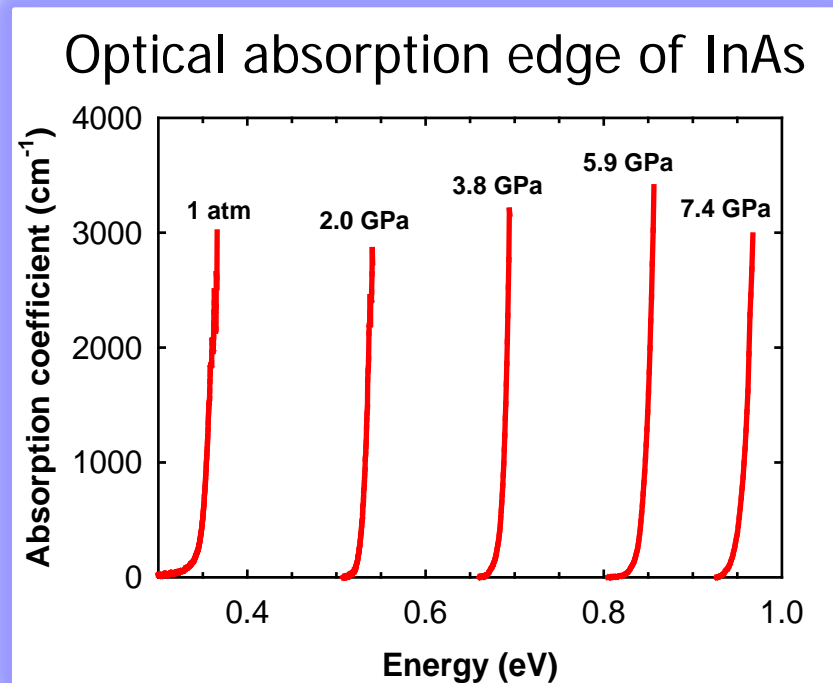
Pressure coefficient InP: 85 meV/GPa

Pressure coefficient InAs: 100 meV/GPa?

- ✓ QWrs and QWs pressure coefficients similar to those of InAs?
- ✓ Slightly larger pressure coefficients for the QW islands than for the QWrs?

Optical absorption in bulk InAs under pressure

Sample thickness: 14 μm
 FIR and MIR: FTIR spectrometer
 NIR: dispersive spectrometer

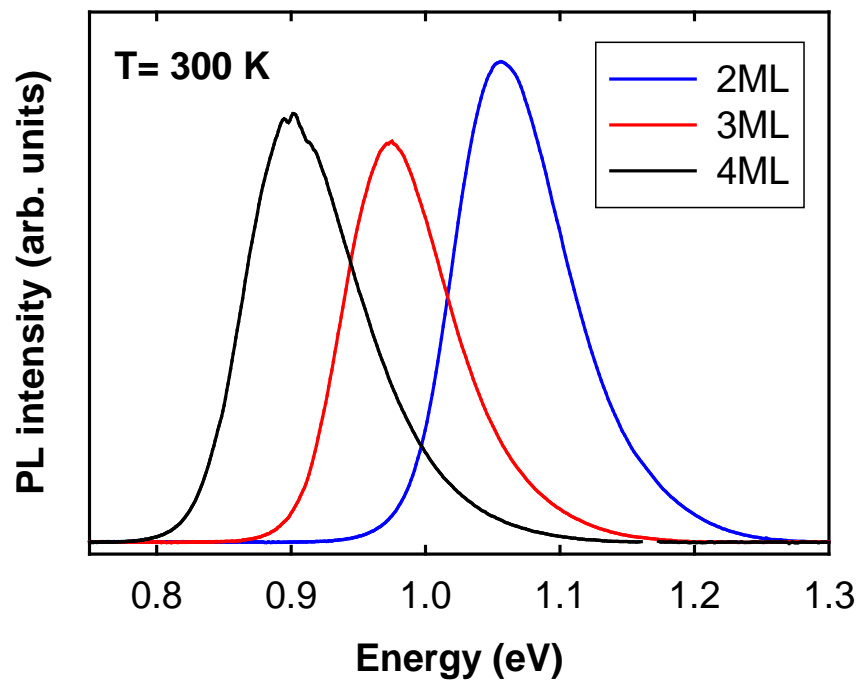


$$E_g = 0.333 + 0.104 \cdot P - 0.003 \cdot P^2$$

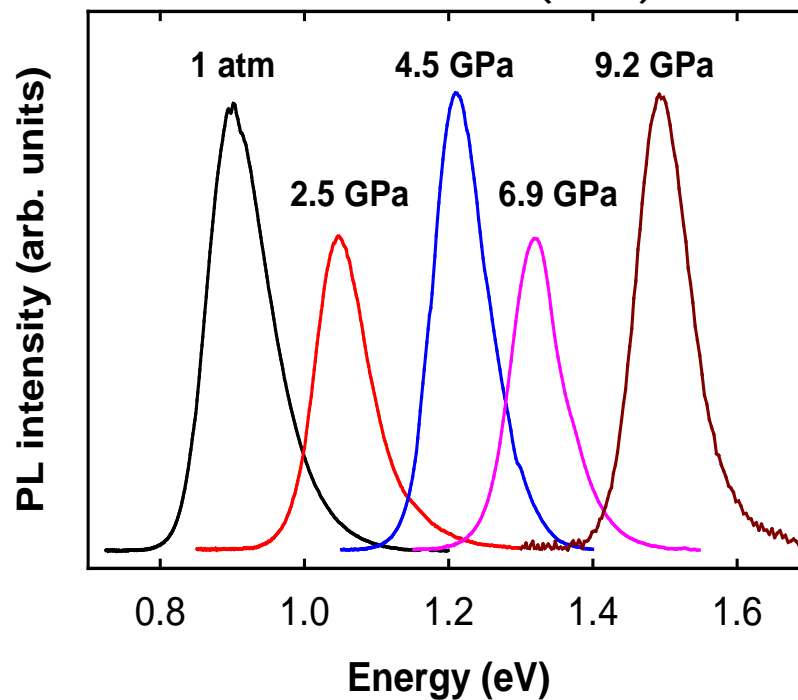
InAs direct bandgap pressure coefficient: 104 4 meV/GPa

PL in InAs/InP quantum wells under pressure

Photoluminescence in InAs/InP QW

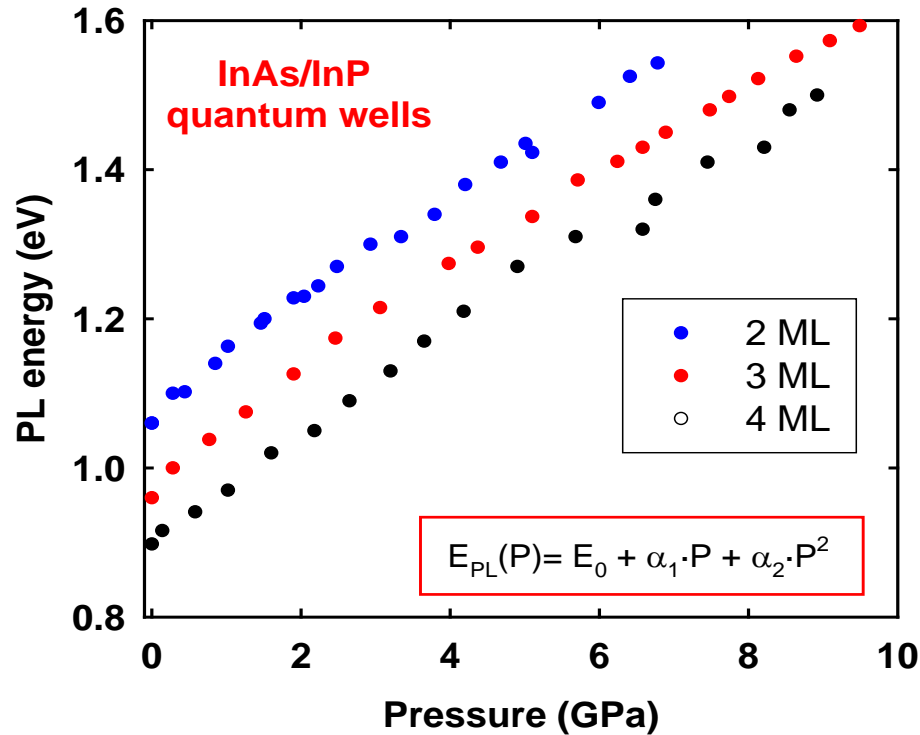


InAs/InP QW (4ML)



InAs/InP	2 ML	3 ML	4 ML
E_0 (eV)	1.055	0.975	0.898

PL in InAs/InP quantum wells under pressure

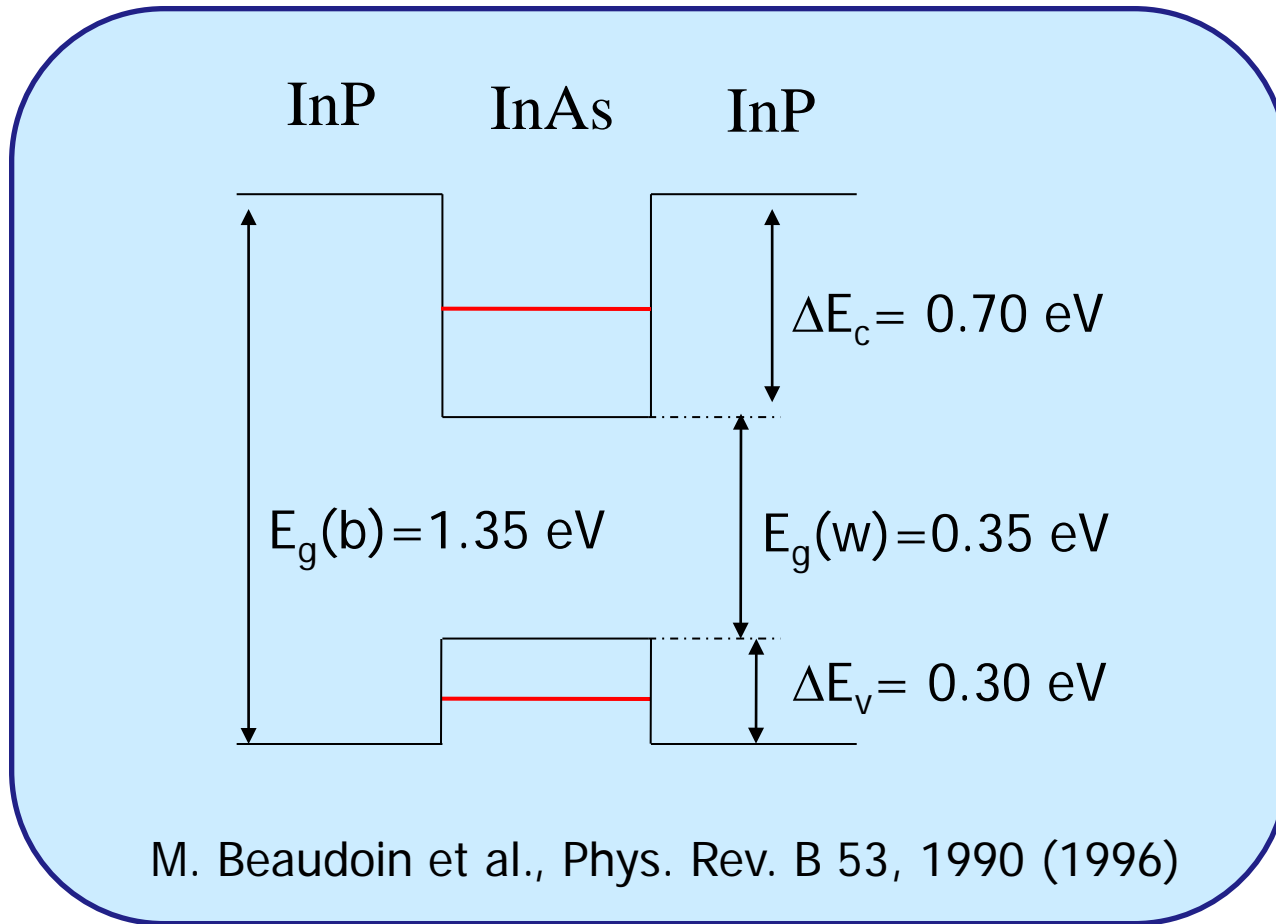


InAs/InP	2 ML	3 ML	4 ML
E_0 (eV)	1.055	0.975	0.898
α_1 (meV/GPa)	89	83	78



Similar PC to InP (85)

PL in InAs/InP quantum wells under pressure

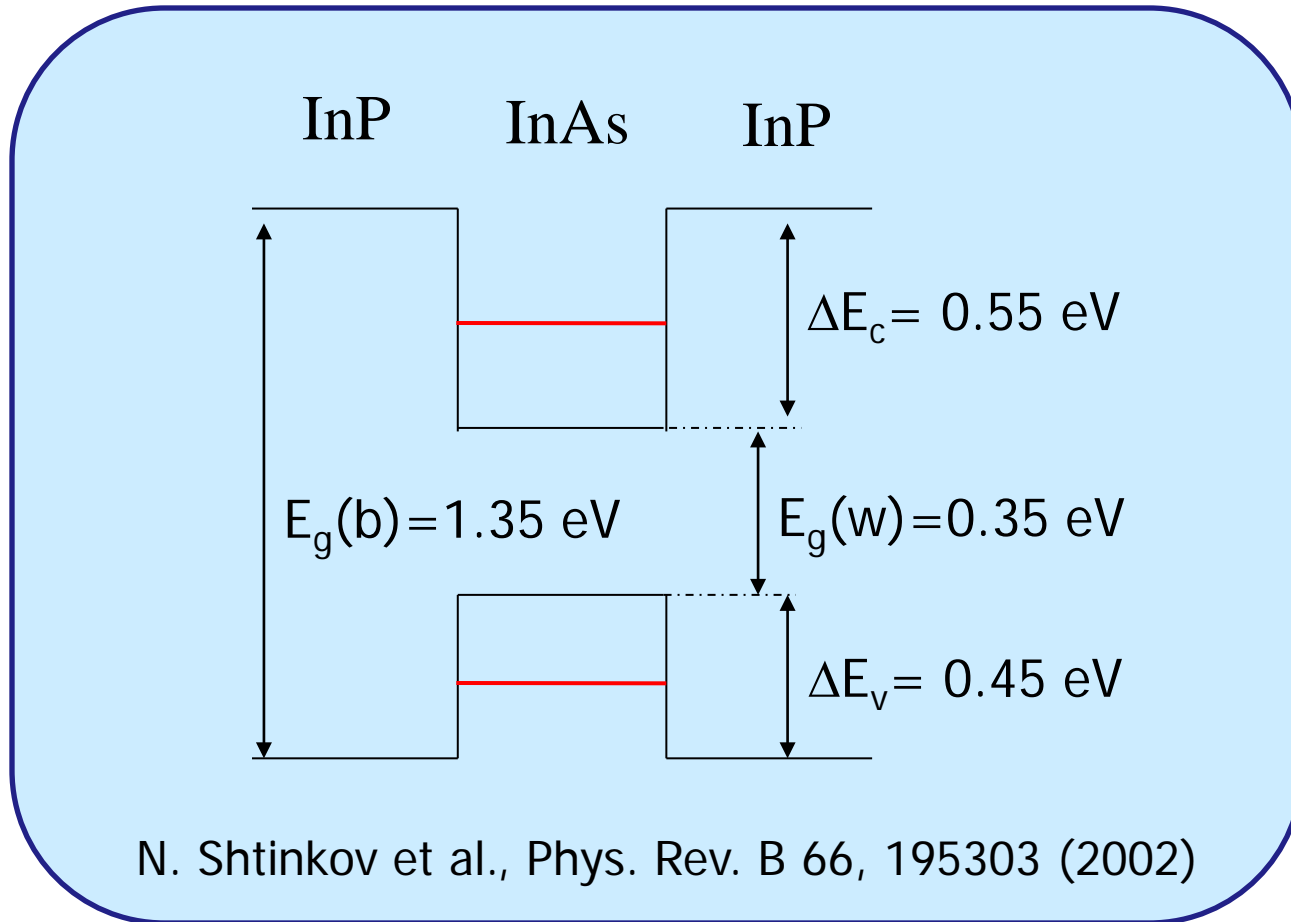


InAs/InP	2 ML	3 ML	4 ML
E_0 (eV)	1.055	0.975	0.898



InAs_xP_{1-x} barrier
with $x \sim 30\%$

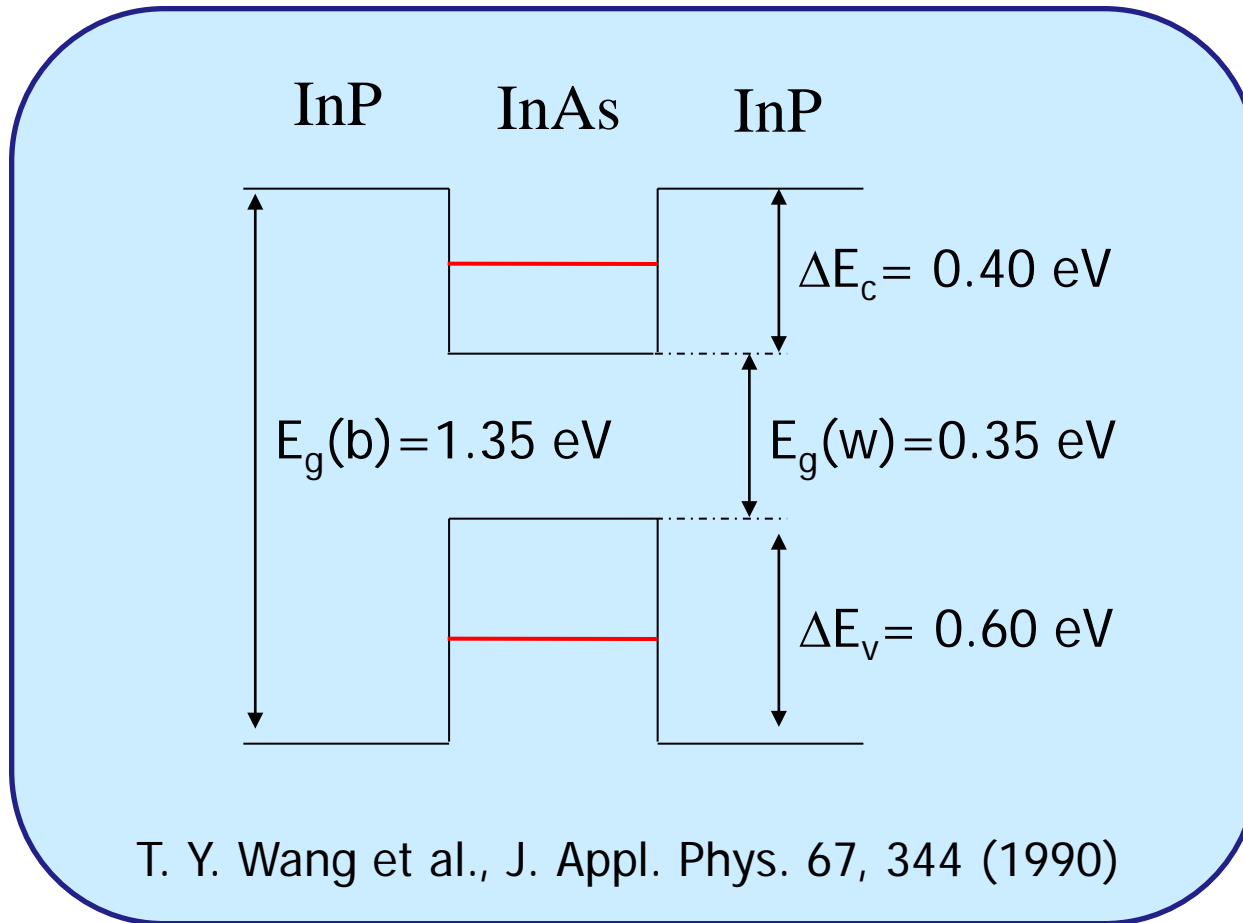
PL in InAs/InP quantum wells under pressure



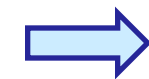
InAs/InP	2 ML	3 ML	4 ML
E_0 (eV)	1.055	0.975	0.898

➔ InAs_xP_{1-x} barrier with x ~ 15%

PL in InAs/InP quantum wells under pressure



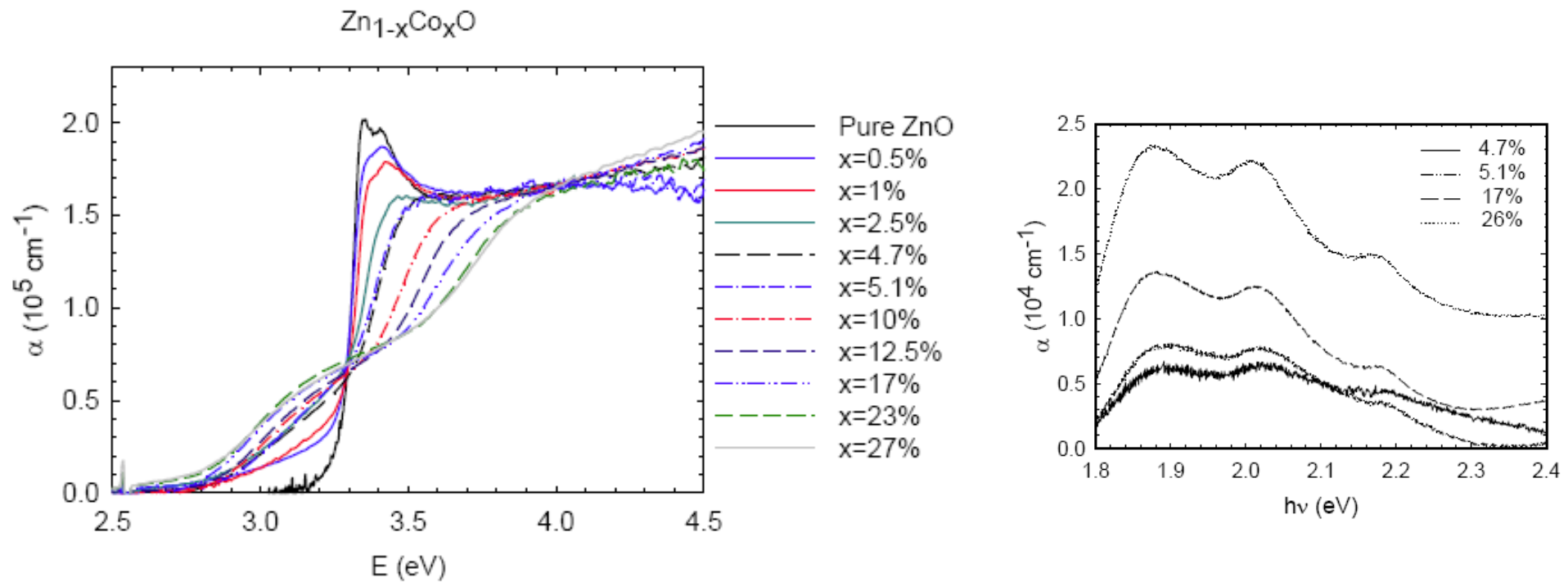
InAs/InP	2 ML	3 ML	4 ML
E_0 (eV)	1.055	0.975	0.898



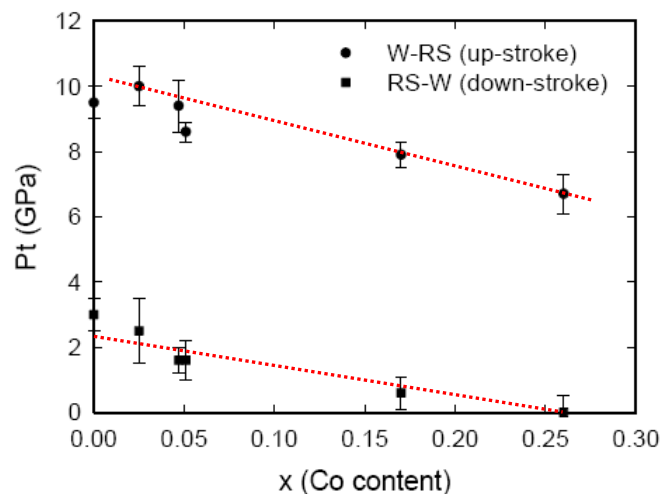
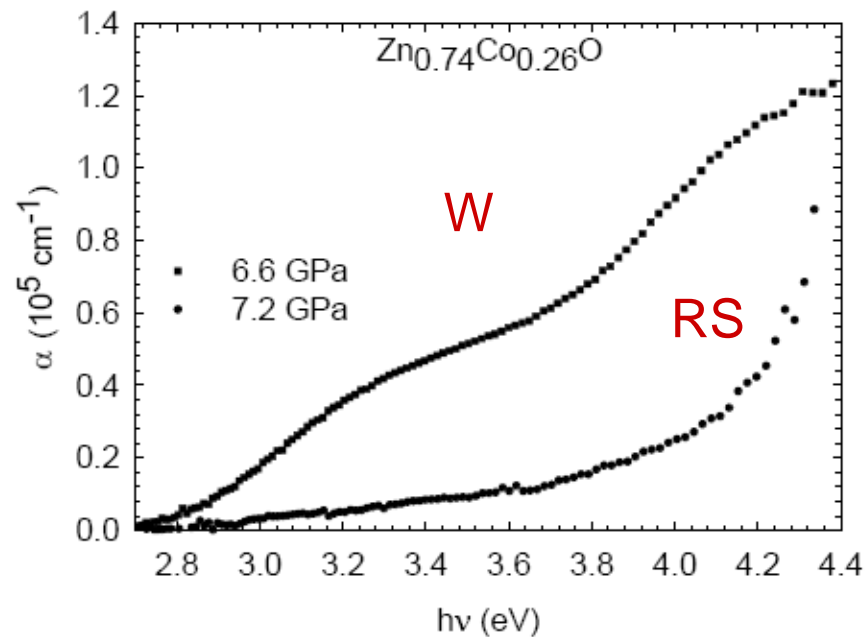
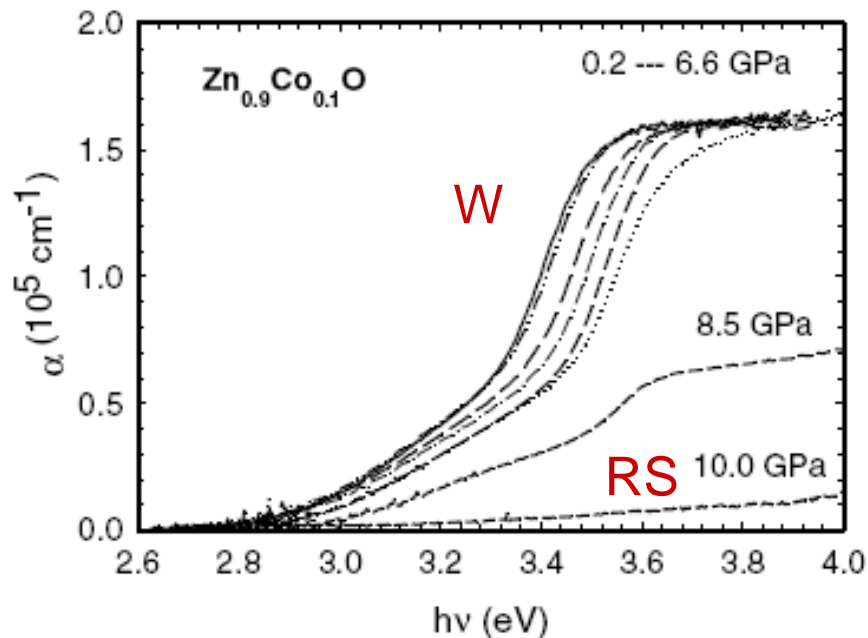
OK

Large metastability range of $Zn_{1-x}Co_xO$ NCs under pressure

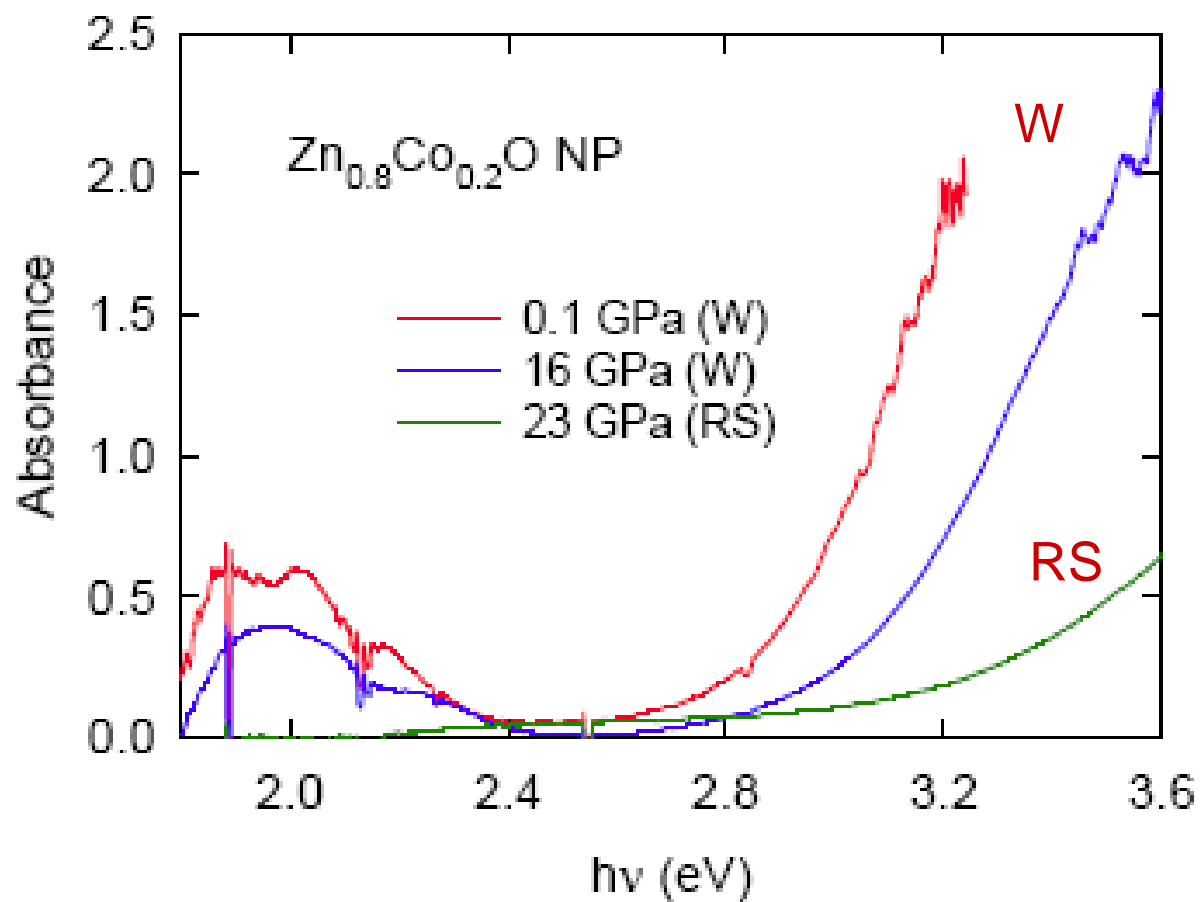
Effect of Co substitution on the optical properties of ZnO (thin films)



Structural phase transitions in $Zn_{1-x}Co_xO$ thin films under pressure

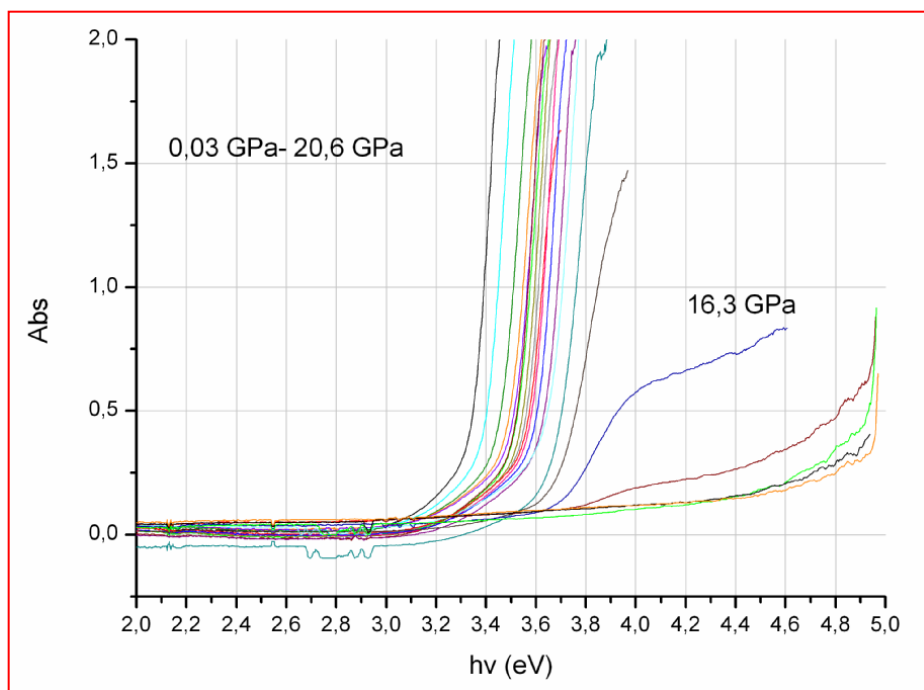


Absorption edge of $Zn_{1-x}Co_xO$ NCs under pressure

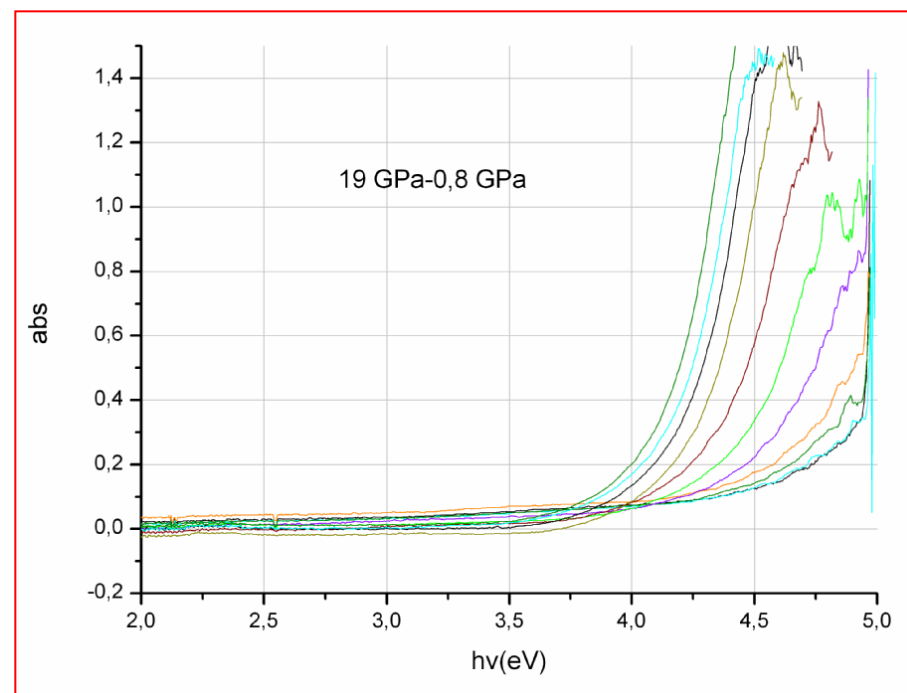


Absorption edge of $Zn_{1-x}Co_xO$ NCs under pressure ($x=0.01$)

Up-stroke

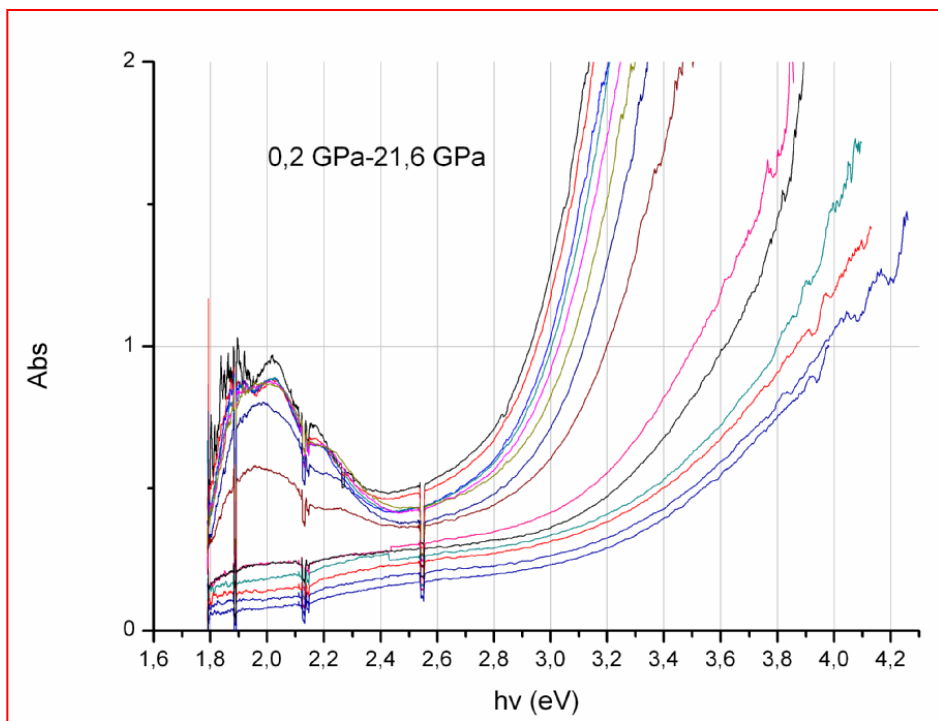


Down-stroke

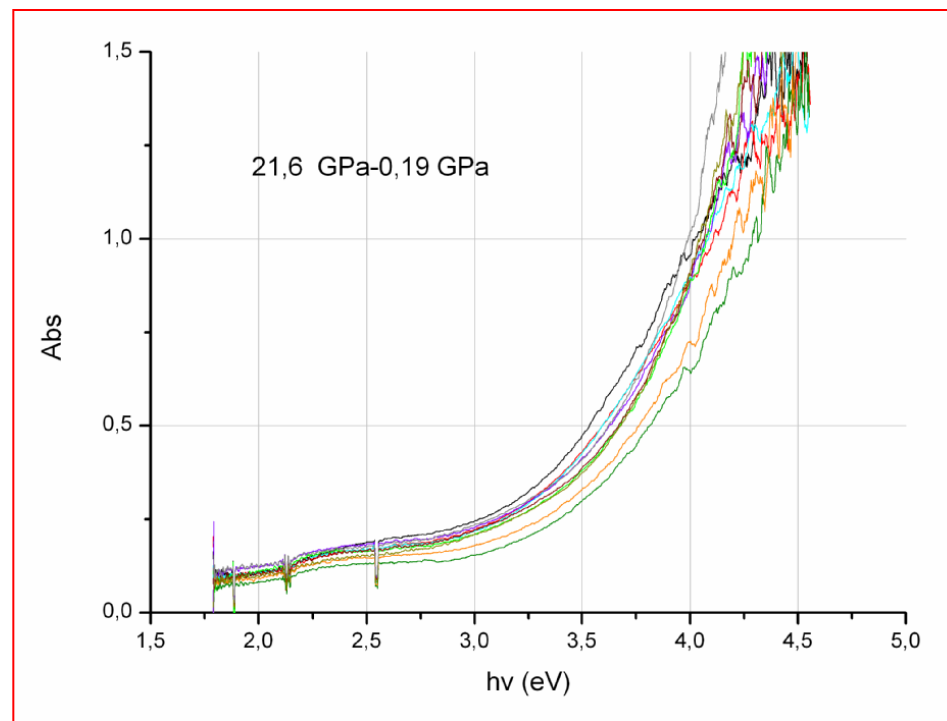


Absorption edge of $Zn_{1-x}Co_xO$ NCs under pressure ($x=0.20$)

Up-stroke



Down-stroke



Conclusions

- 1) Optical absorption and photoluminescence experiments under pressure can be an useful tool to investigate the electronic structure of semiconductor nanostructures.
- 2) In some cases the interpretation of the results requires sophisticated theoretical methods beyond simple effective mass models.
- 3) High pressure is also an interesting tool in the preparation of new meta-stable nanostructures.
- 4) To improve the power of HP methods in nanoscience, by increasing the spatial resolution, new diamond anvil cells can be designed allowing for the use of shorter working distance objectives.

PbSe NCs

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InAs QWrs and QWs

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ZnCoO NCs

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